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**REQUEST
FOR
CONTINUED EXAMINATION (RCE)
TRANSMITTAL**

Subsection (b) of 35 U.S.C. § 132, effective on May 29, 2000, provides for continued examination of an utility or plant application filed on or after June 8, 1995.

See The American Inventors Protection Act of 1999 (AIPA).

Application Number	09/295,607
Filing Date	April 22, 1999
First Named Inventor	Shunpei YAMAZAKI et al.
Group Art Unit	2811
Examiner Name	S. LOKE
Attorney Docket Number	740756-1961

This is a Request for Continued Examination (RCE) under 37 C.F.R. § 1.114 of the above-identified application.

NOTE: 37 C.F.R. § 1.114 is effective on May 29, 2000. If the above-identified application was filed prior to May 29, 2000, applicant may wish to consider filing a continued prosecution application (CPA) under 37 C.F.R. § 1.53(d) (PTO/SB/29) instead of a RCE to be eligible for the patent term adjustment provisions of the AIPA. See Changes to Application Examination and Provisional Application Practice, Final Rule, 65 Fed. Reg. 50092 (Aug. 16, 2000); Interim Rule, 65 Fed. Reg. 14865 (Mar. 20, 2000), 1233 Off. Gaz. Pat. Office 47 (Apr. 11, 2000), which established RCE practice.

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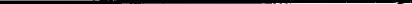
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02 FC:102
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SIGNATURE OF APPLICANT, ATTORNEY, OR AGENT REQUIRED

Name (Print/Type)	Luan C. Do	Registration No. (Attorney/Agent)	38,434
Signature		Date	December 17, 2001 (Monday)

CERTIFICATE OF MAILING OR TRANSMISSION

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to: Commissioner For Patents, Box RCE, Washington, DC 20231, or facsimile transmitted to the U.S. Patent and Trademark Office on:

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BOX AFTER FINAL
EXPEDITED PROCEDURE
Docket No.: 740756-1961

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT application of)
Shunpei YAMAZAKI et al.) Group Art Unit: 2811
Serial No. 09/295,607) Examiner: S. Loke
Filed: April 22, 1999)
For: SEMICONDUCTOR DEVICE HAVING)
ALUMINUM NITRIDE FILM)

#30/E
1-19-02
Paxton

AMENDMENT AFTER FINAL

Assistant Commissioner for Patents
Washington, D.C. 20231

December 17, 2000

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Sir:

In response to the Final Office Action of March 16, 2001, please amend the above-identified application and consider Applicants' remarks as follows:

IN THE CLAIMS:

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Please amend claims 2, 3, 6-8, 19-24, 32-35, 37-55, 57, and 58 as follows:

2. (Amended) A semiconductor device comprising:

 a substrate having a front surface and a rear surface;

 fig. 1E
 an aluminum nitride insulating film containing therein oxygen provided under
 said rear surface of the substrate; and

 fig. 1E
 a transistor provided over said front surface of the substrate, said transistor having
 at least a channel formation region comprising crystalline silicon, a gate insulating film adjacent
 to said channel formation region, and a gate electrode adjacent to said channel formation region
 with said gate insulating film interposed therebetween.

3. (Amended) A semiconductor device comprising:

 fig. 12E
 a substrate having a front surface and a rear surface;